

Functional Inorganic Materials

Fall 2023

Mondays: 10.15 - 12.00
Thursdays: 10.15 - 12.00

Lecture hall locations: U7 in Otakaari 1 / U-wing
Ke1 in Kemistintie 1 (CHEM building)

You can use <https://usefulaaltomap.fi/> to see the exact location of U7.

#	Date	Place	Who	Topic
1	Mon 4.9.	U7 (U135a)	Maarit	Introduction + Materials design
2	Thu 7.9.	Ke1 (A305)	Antti	Introduction + Computational materials design
3	Mon 11.9.	U7 (U135a)	Maarit	Superconductivity: High-T _c superconducting Cu oxides
4	Thu 14.9.	Ke1 (A305)	Maarit	Magnetic oxides
5	Mon 18.9.	U7 (U135a)	Maarit	Ionic conductivity (Oxygen): Oxygen storage and SOFC
6	Thu 21.9.	Ke1 (A305)	Maarit	Ionic conductivity (Lithium): Li-ion battery
7	Mon 25.9.	U7 (U135a)	Antti	Thermal conductivity
8	Thu 28.9.	Ke1 (A305)	Antti	Thermoelectricity
9	Mon 2.10.	U7 (U135a)	Antti	Piezoelectricity
10	Thu 5.10.	Ke1 (A305)	Antti	Pyroelectricity and ferroelectricity
11	Mon 9.10.	U7 (U135a)	Antti	Luminescent and optically active materials
12	Thu 12.10.	Ke1 (A305)	Maarit	Hybrid materials

LECTURE 1: Materials Design Concepts

- EXAMPLE: Electrical conductivity & Charge carrier concentration
- n-type (electrons) & p-type (holes) conductivity
- Doping & Substitution
- Aliovalent Substitution (vs. isovalent subst.) & Mixed Valency
- Nonstoichiometry: Vacancies (deficiency) & Interstitials (excess)
- Relative Ion Sizes & Tolerance Parameter
- OTHER KEYWORDS:
Band structure, Crystal field splitting & Jahn-Teller distortion

We first recall the doping scheme in elemental semiconductors (Si) which you have learned in your basic studies.

Then, we have a look on how the situation is similar/different for chemical compounds (of major focus in this course),
using ZnO and perovskite metal oxides as examples.

LECTURE EXERCISE 1

1. Discuss in a comparative manner the doping schemes in Si (elemental semiconductor), ZnO (simple metal oxide) and complex transition metal oxides (perovskites).
2. Assign the type of doped carriers (n-type or p-type) for the following materials, and rationalize your answers: Al-doped Si, Al-doped ZnO, $(\text{Pb}_{0.98}\text{Na}_{0.02})\text{Te}$, $(\text{La}_{0.9}\text{Sr}_{0.1})_2\text{CuO}_{4.0}$, $\text{La}_2\text{CuO}_{4.1}$.
3. Calculate tolerance parameters for the following perovskite compounds (using ionic radius values given below), and judge whether the compounds are feasible. Also, predict in which of them it is most easy to create oxygen vacancies; explain why: LaMnO_3 , LaCoO_3 , LaNiO_3 , LaCuO_3 .

IONIC RADII:		
	La^{3+}	1.36 Å
	Mn^{3+}	0.65 Å
	Co^{3+}	0.61 Å
	Ni^{3+}	0.60 Å
	Cu^{3+}	0.54 Å
	O^{2-}	1.40 Å

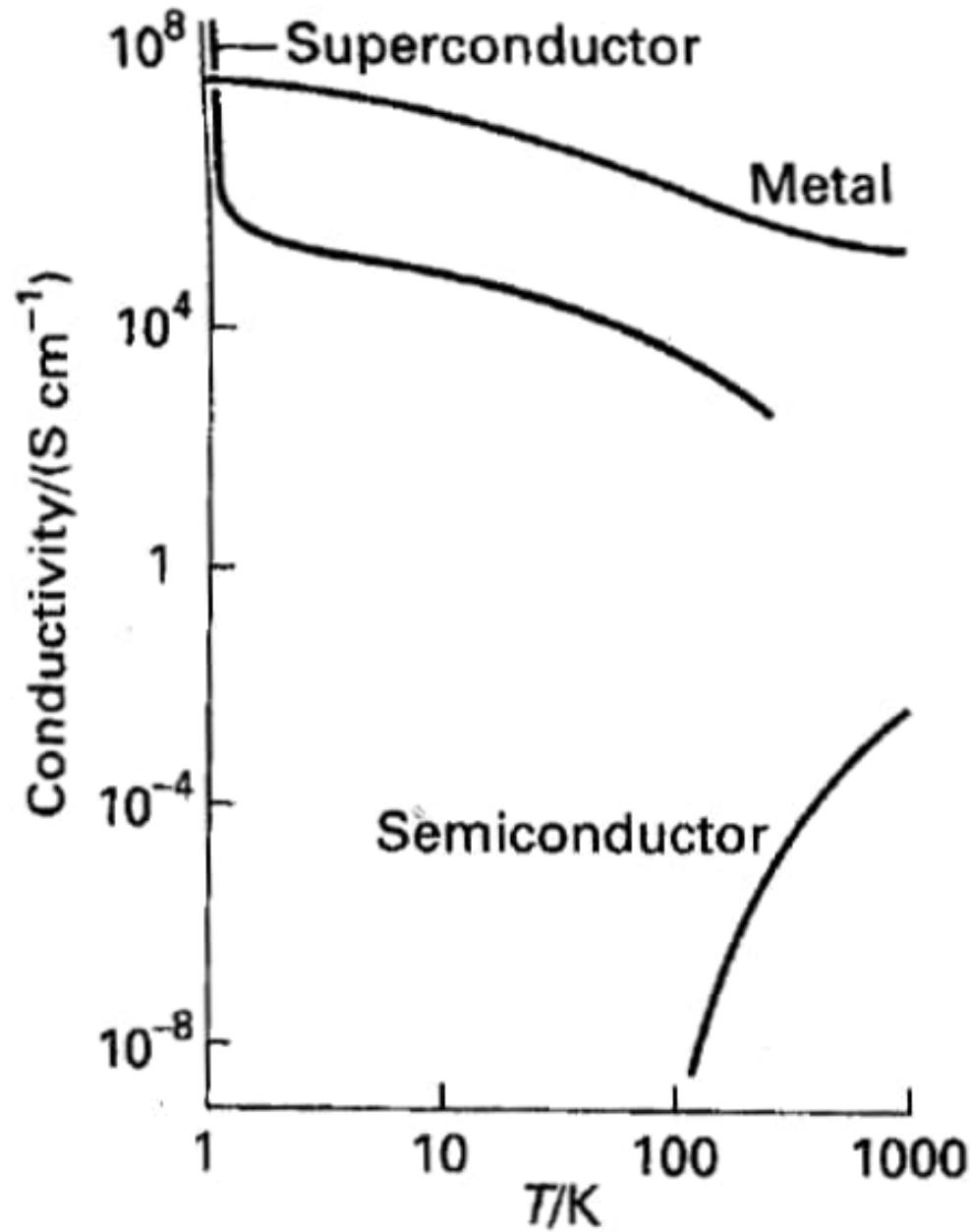
Periodic table of the elements

period	group	1*	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18
1	group 1*	H	He	Li	Be	Na	Mg	Al	Si	P	S	Cl	Ar	B	C	N	O	F	Ne
2		3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18		
3		K	Ca	Sc	Ti	V	Cr	Mn	Fe	Co	Ni	Cu	Zn	Ga	Ge	As	Se	Br	Kr
4		Rb	Sr	Y	Zr	Nb	Mo	Tc	Ru	Rh	Pd	Ag	Cd	In	Sn	Sb	Te	I	Xe
5		Cs	Ba	La	Hf	Ta	W	Re	Os	Ir	Pt	Au	Hg	Tl	Pb	Bi	Po	At	Rn
6		Fr	Ra	Ac	Rf	Db	Sg	Bh	Hs	Mt	Ds	Rg	Cn	Nh	Fl	Mc	Lv	Ts	Og
7		lanthanoid series			58	59	60	61	62	63	64	65	66	67	68	69	70	71	
		actinoid series			Ce	Pr	Nd	Pm	Sm	Eu	Gd	Tb	Dy	Ho	Er	Tm	Yb	Lu	
					90	91	92	93	94	95	96	97	98	99	100	101	102	103	
					Th	Pa	U	Np	Pu	Am	Cm	Bk	Cf	Es	Fm	Md	No	Lr	

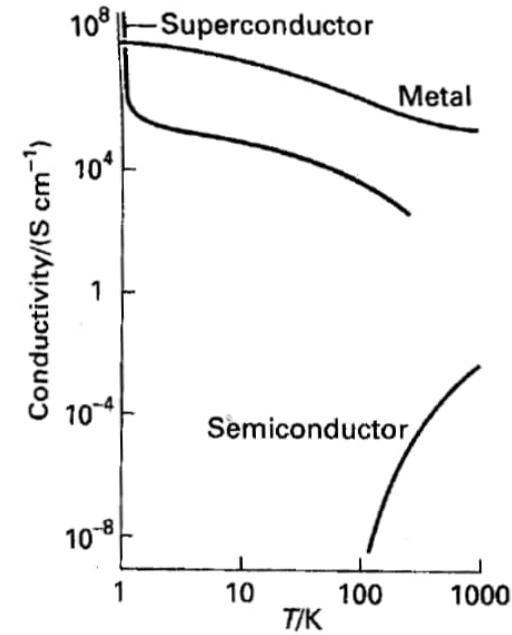
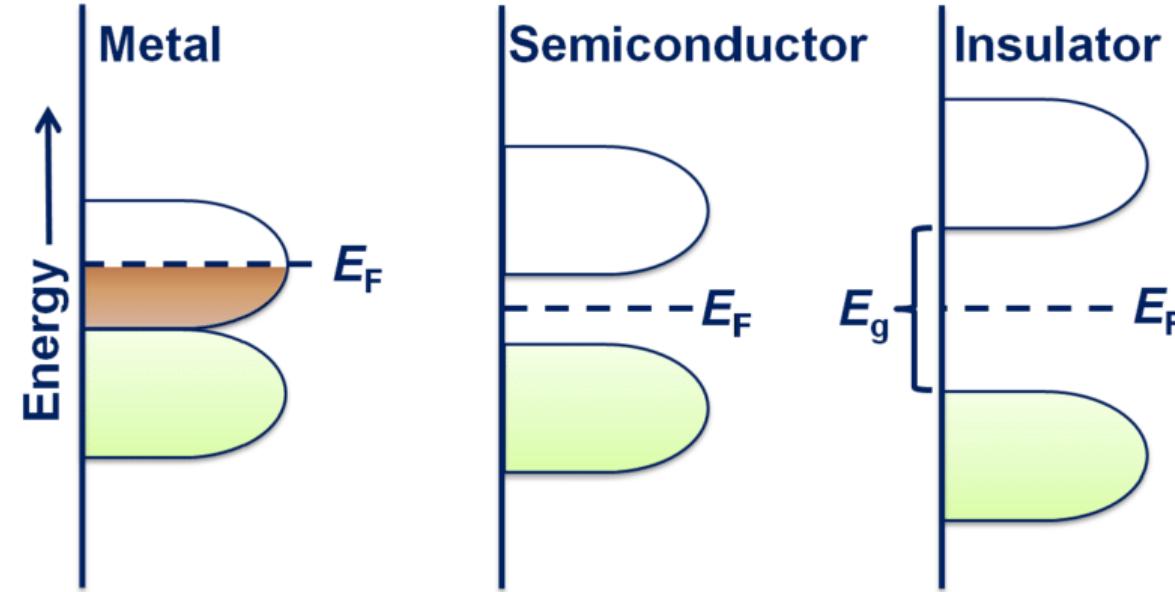
*Numbering system adopted by the International Union of Pure and Applied Chemistry (IUPAC).

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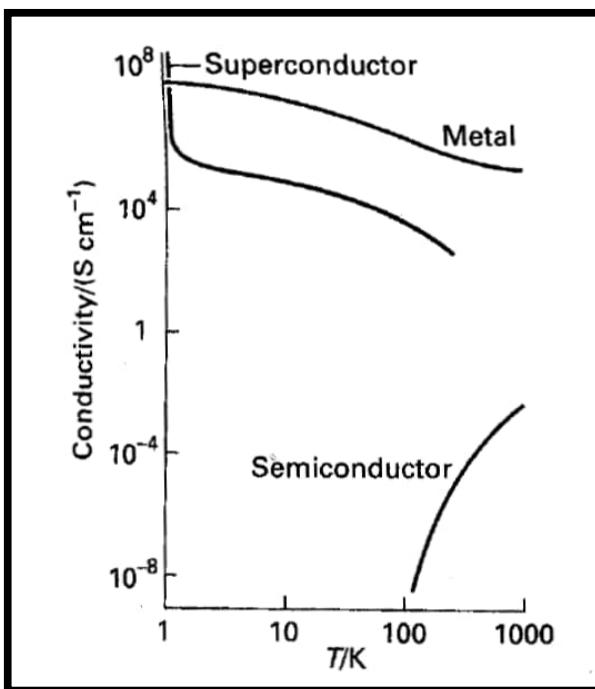
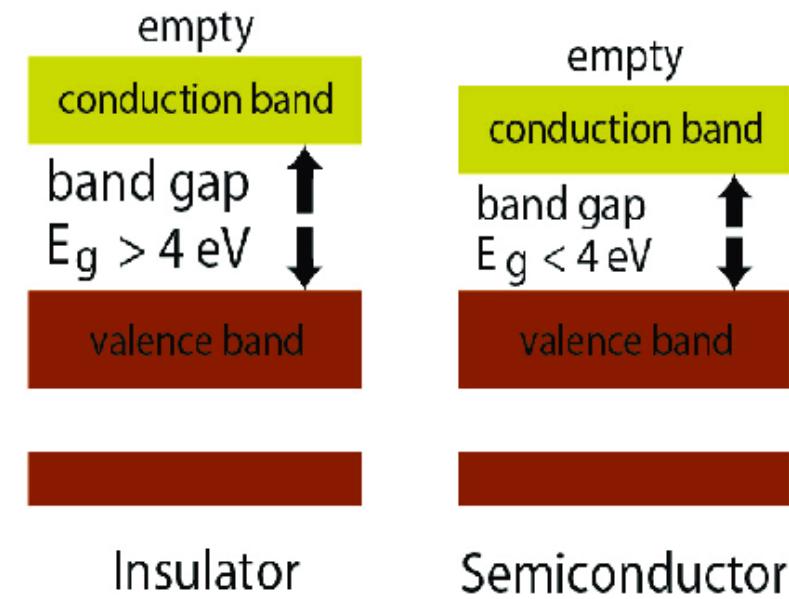
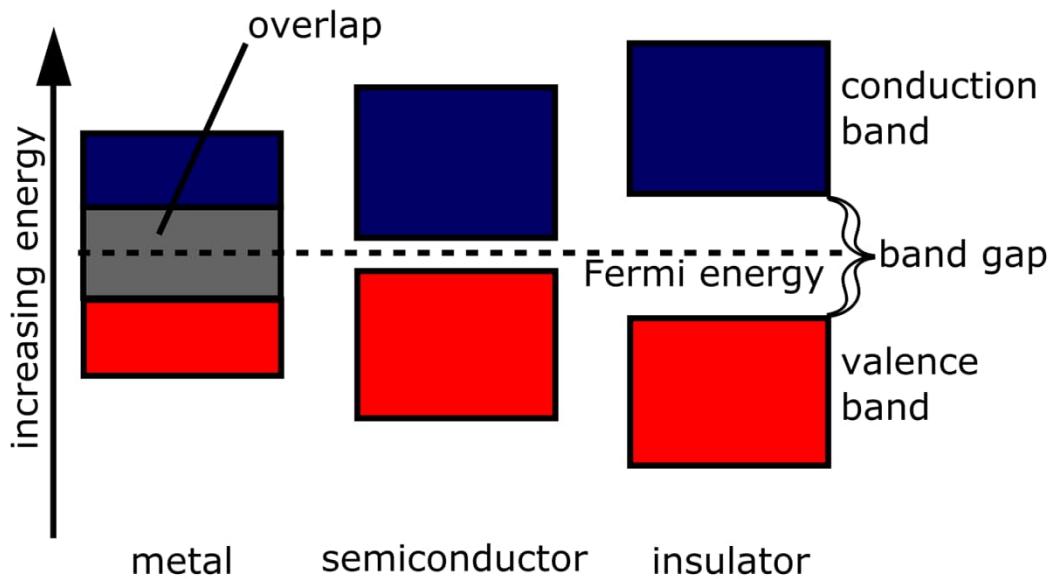
ELECTRICAL CONDUCTIVITY



Schematic Band Structures



- Recall the meanings of E_F and E_g
- What is the x-axis ?
- How large is E_g for a semiconductor / an insulator ?
- Can you explain the different temperature dependencies of electrical conductivity for metals and semiconductors ?



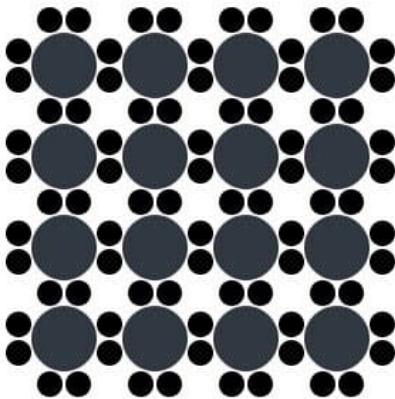
n-type: donor
p-type: acceptor

Periodic table of the elements																			
group 1 ⁺	Alkali metals			Halogens			Noble gases												
	Alkaline-earth metals			Rare-earth elements (21, 39, 57–71) and lanthanoid elements (57–71 only)															
1	H	2	Li	Be	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17
2	Na	Mg	Sc	Ti	V	Cr	Mn	Fe	Co	Ni	Cu	Zn	Ga	Al	B	C	N	O	He
3	K	Ca	21	22	23	24	25	26	27	28	29	30	31	32	33	34	35	36	Kr
4	Rb	Sr	39	40	41	42	43	44	45	46	47	48	49	50	51	52	53	54	Xe
5	Cs	Ba	La	Hf	Ta	W	Re	Os	Ir	Pt	Au	Hg	Tl	Pb	Bi	Po	At	Rn	
6	Fr	Ra	Ac	104	105	106	107	108	109	110	111	112	113	114	115	116	117	118	Og
lanthanoid series		6	58	59	60	61	62	63	64	65	66	67	68	69	70	71			
actinoid series		7	Ce	Pr	Nd	Pm	Sm	Eu	Gd	Tb	Dy	Ho	Er	Tm	Yb				
			90	91	92	93	94	95	96	97	98	99	100	101	102	103	Lr		
			Th	Pa	U	Np	Pu	Am	Cm	Bk	Cf	Es	Fm	Md	No				

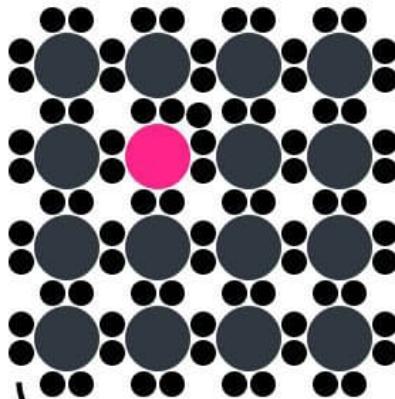
*Numbering system adopted by the International Union of Pure and Applied Chemistry (IUPAC). © Encyclopædia Britannica, Inc.

Doping in Semiconductors

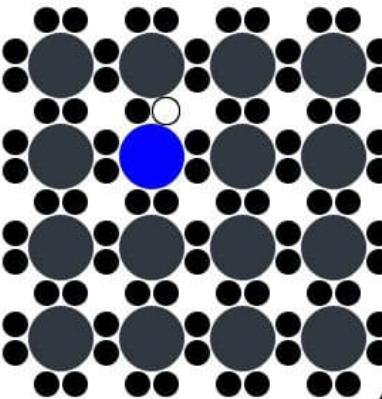
Array of Si atoms



n-type semiconductor



p-type semiconductor



Doped semiconductor



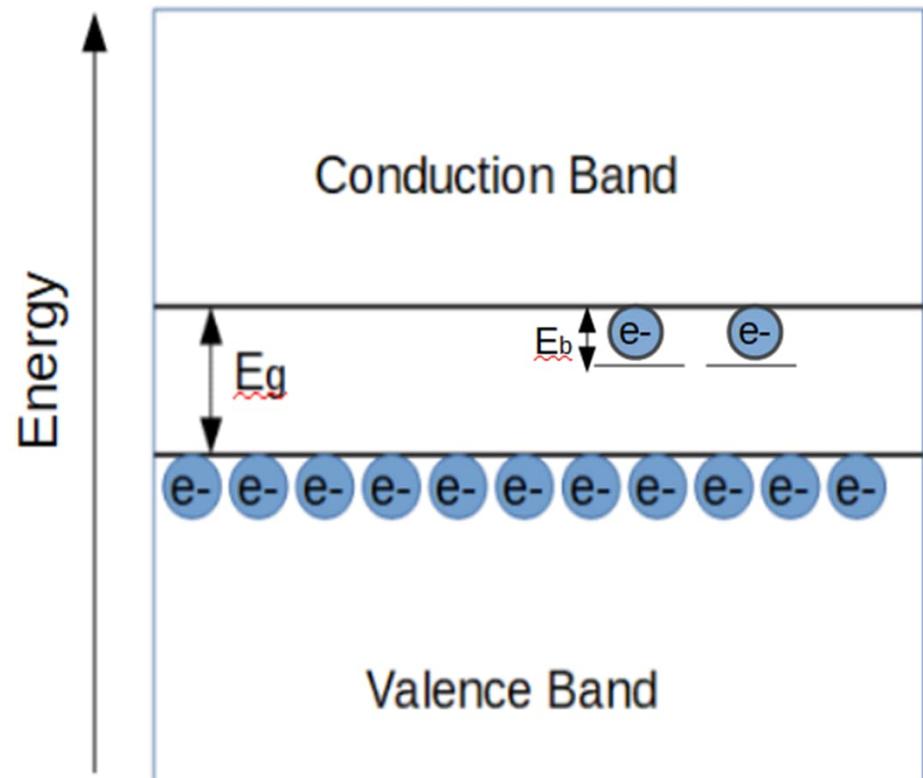
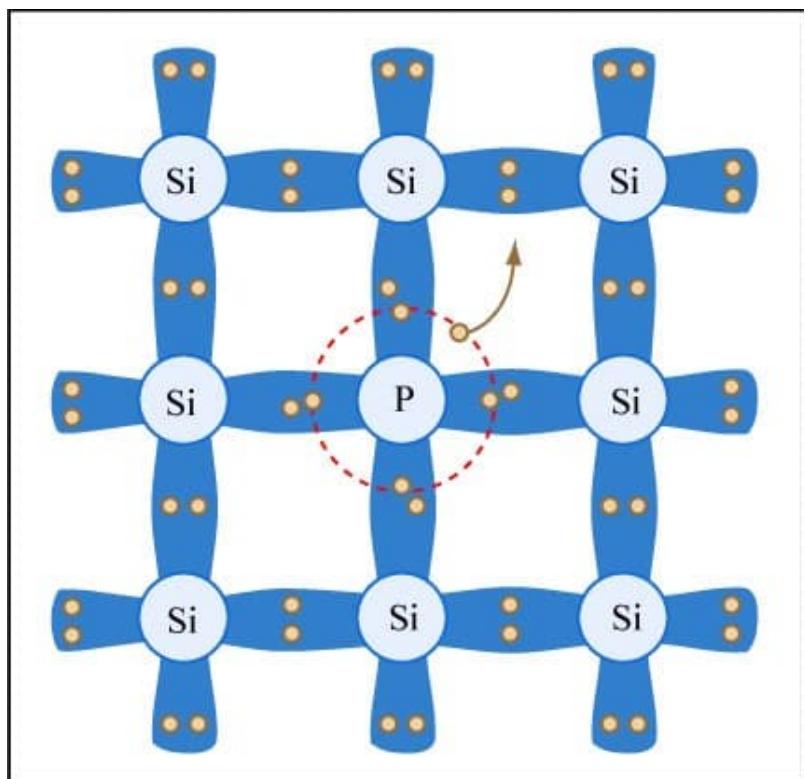
● Electron



Boron

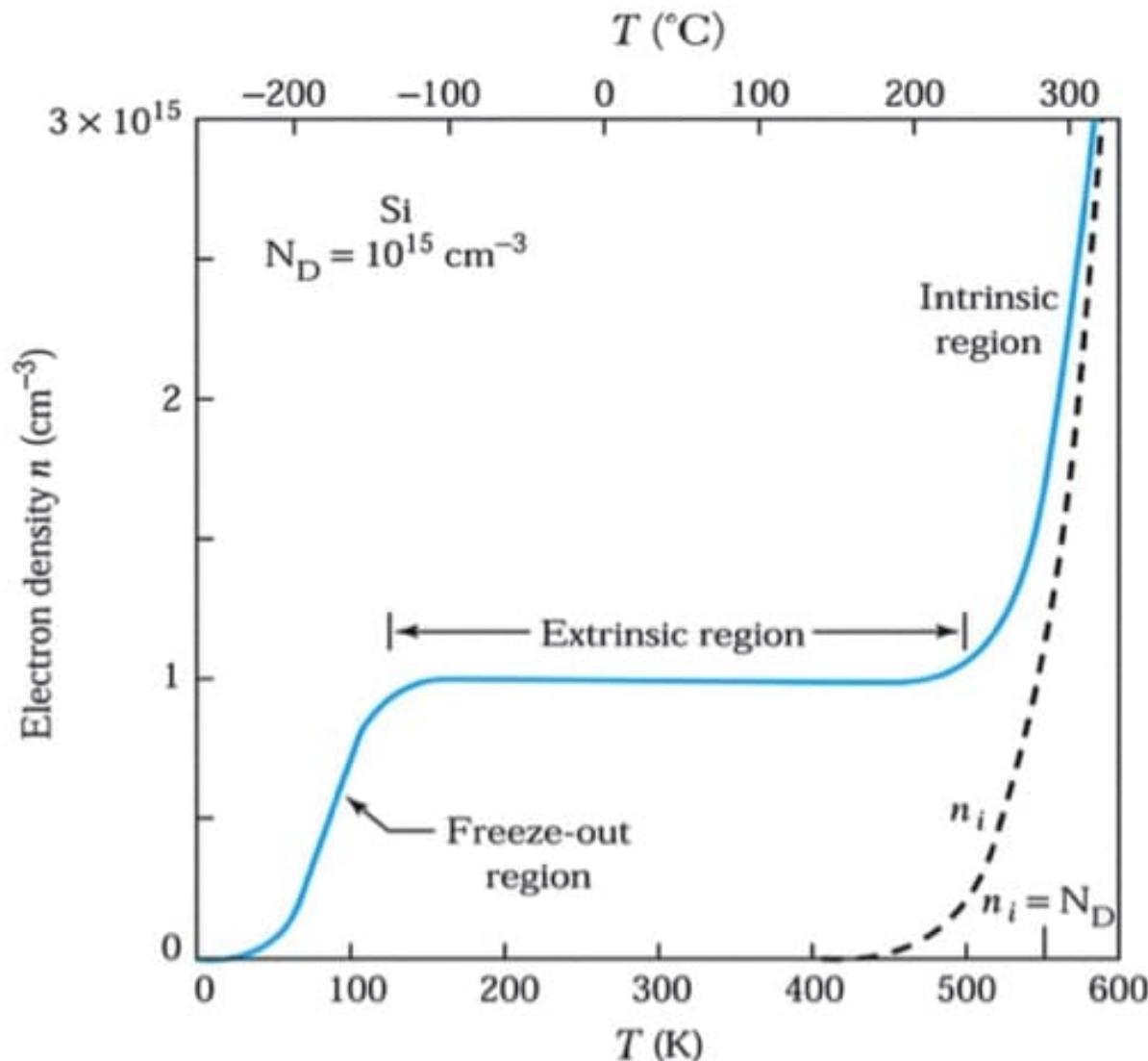
n-type doping:

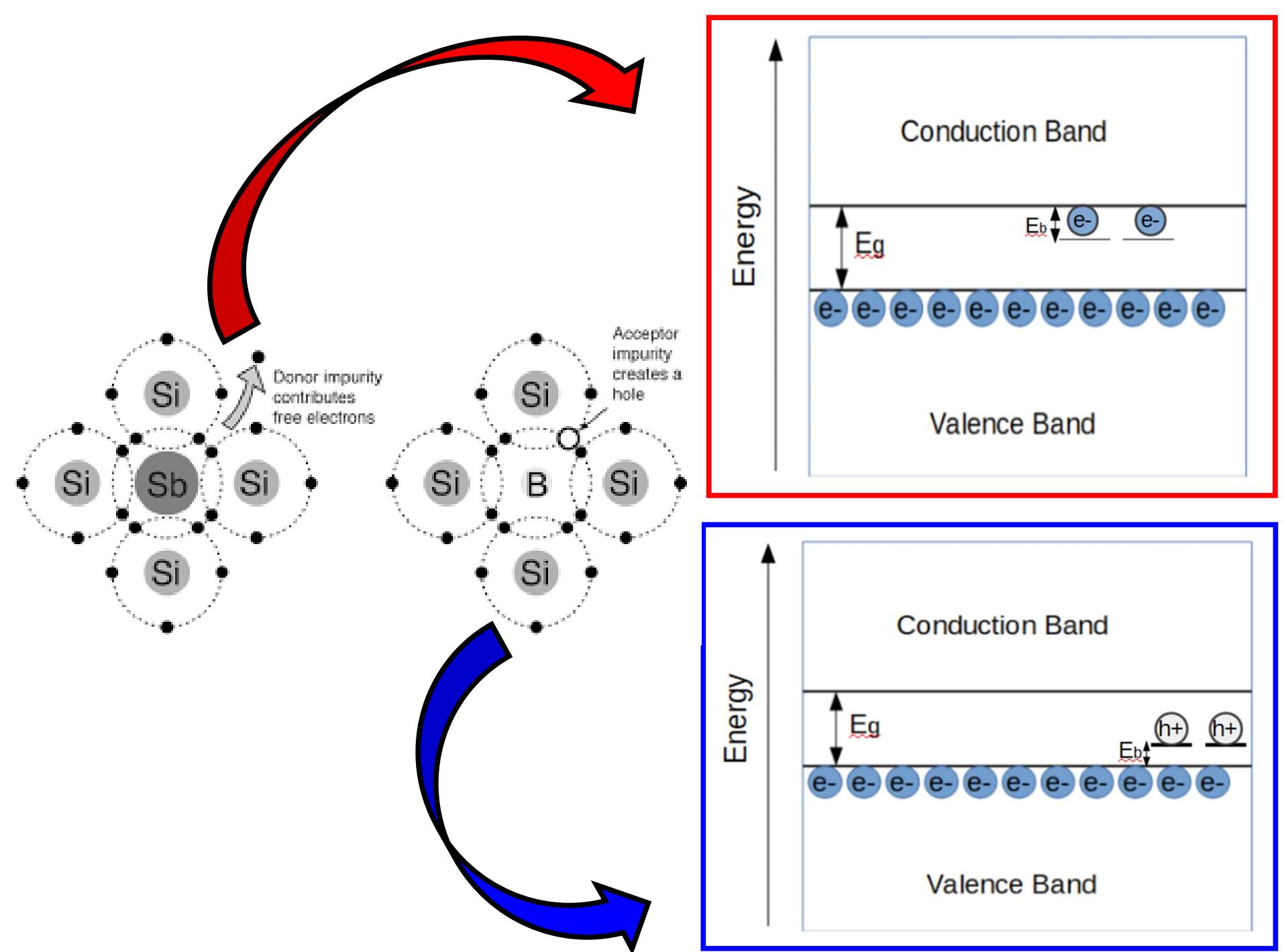
- Si: 4 valence electrons
- P: 5 valence electrons (= 1 extra)



Si atoms: $5 \cdot 10^{22} \text{ cm}^{-3}$

Dopant atoms: 10^{15} cm^{-3}





ALIOVALENT SUBSTITUTION

n-type doping: “higher valent”

e.g. P(V) e.g. for Si(IV)

p-type doping: “lower valent”

e.g. B(III) for Si(IV)

Simple metal oxide semiconductor: ZnO

- Intrinsically n-type: “native” or “unintentionally occurring” defects;
What kind of defects could be responsible for n-type doping ?
 - ☒ n-type: “higher positive valence”
 - ☒ Slight excess of Zn(II) (at interstitial sites)
 - ☒ Proton (H^+) interstitials
- Intentional n-type doping: typically Al(III) for Zn(II)
- p-type doping very much desired but has turned out to be difficult

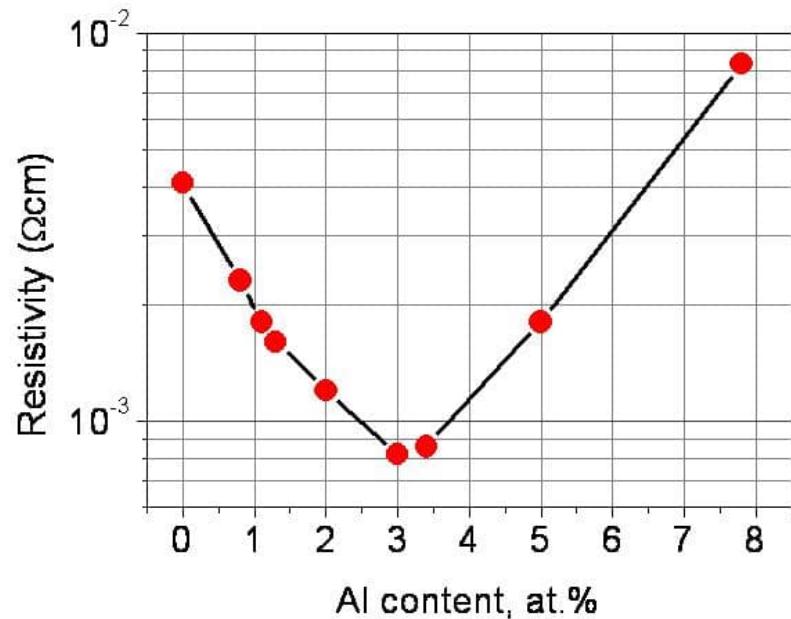
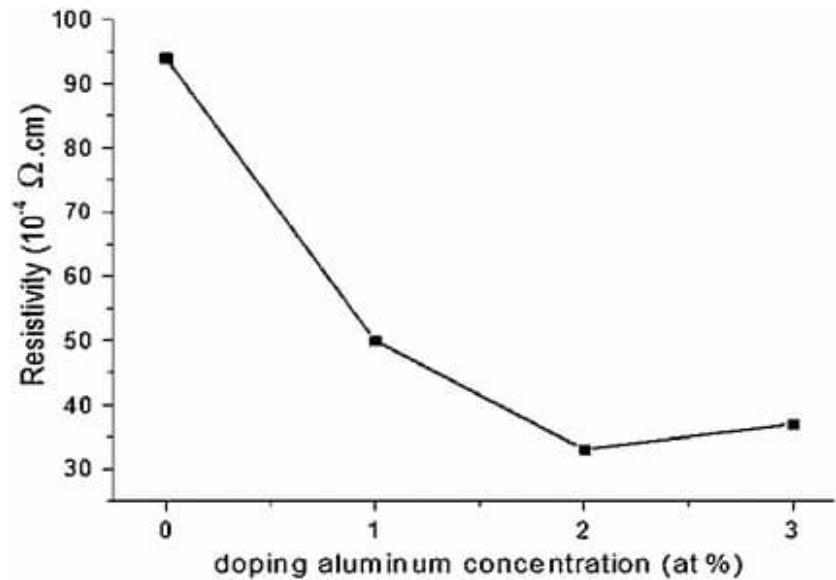
Elements used for doping ALD ZnO

Elements used for doping ALD ZnO																	
H																	
Li	Be																
Na	Mg																
K	Ca	Sc	Ti	V	Cr	Mn	Fe	Co	Ni	Cu	Zn	Ga	Ge	As	Se	Br	Kr
Rb	Sr	Y	Zr	Nb	Mo	Tc	Ru	Rh	Pd	Ag	Cd	In	Sn	Sb	Te	I	Xe
Cs	Ba		Hf	Ta	W	Re	Os	Ir	Pt	Au	Hg	Tl	Pb	Bi	Po	At	Rn
Fr	Ra		Rf	Db	Sg	Bh	Hs	Mt	Ds	Rg	Cn	Nh	Fl	Mc	Lv	Ts	Og
Lanthanides	La	Ce	Pr	Nd	Pm	Sm	Eu	Gd	Tb	Dy	Ho	Er	Tm	Yb	Lu		
Anatropes	Ac	Th	Pa	U	Np	Pu	Am	Cm	Bk	Cf	Es	Fm	Md	No	Lr		

Zhengning Gao and Parag Banerjee, Review Article: Atomic layer deposition of doped ZnO films, Journal of Vacuum Science & Technology A **37**, 050802 (2019);
<https://doi.org/10.1116/1.5112777>

INTENTIONAL DOPING: typical substitution level ?

Typical aluminum substitution level in ZnO ?



Perovskite – Multifunctional structure

Perovskite
 ABO_3

Ion conductor
 $\text{La}(\text{Co},\text{Ga})\text{O}_3$

Electric insulator
 SrTiO_3

Superconductor
 $\text{CuBa}_2\text{YCu}_2\text{O}_{6+z}$

Capasitor
(high dielectric constant)
 BaTiO_3

Magnetoresistor
 LaMnO_3

Piezoelectric material
 $\text{Pb}(\text{Zr},\text{Ti})\text{O}_3$

Record-high melting point
 $\text{Ba}_3\text{MgTa}_2\text{O}_9$

Metallic conductor
 LaCrO_3

Major constituent of earth
 MgSiO_3

Catalyst
 $\text{La}(\text{Co},\text{Mn})\text{O}_3$

PEROVSKITE STRUCTURE

General formula: $\text{ABO}_{3-\delta}$

A: large cation

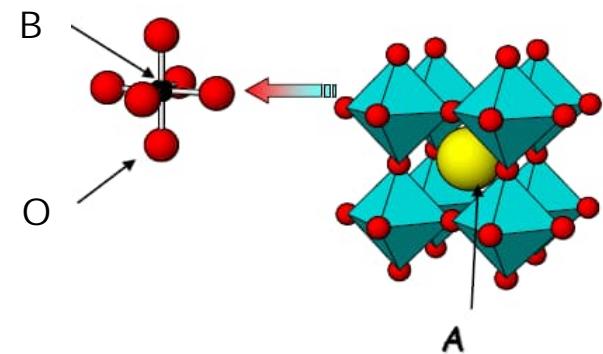
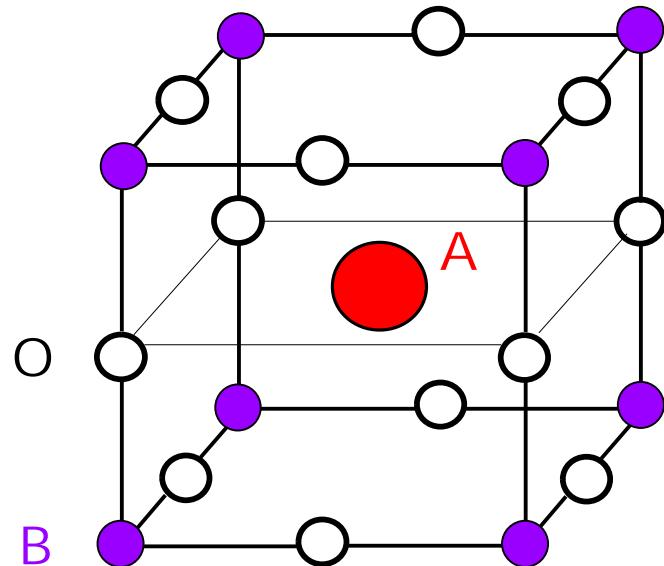
B: small cation (transition metal)

O: oxygen (sometimes halogen)

$$V(\text{A}) + V(\text{B}) = 6$$

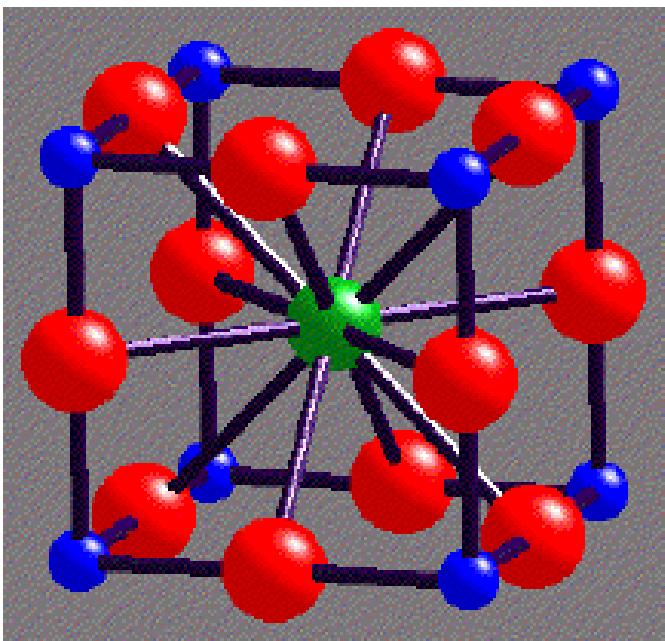
e.g. $\text{La}^{\text{III}}\text{Sc}^{\text{III}}\text{O}_3$, $\text{Sr}^{\text{II}}\text{Ti}^{\text{IV}}\text{O}_3$, $\text{Na}^{\text{I}}\text{Nb}^{\text{V}}\text{O}_3$

$$\text{CN}(\text{A})=12, \text{CN}(\text{B})=6, \text{CN}(\text{O})=6$$

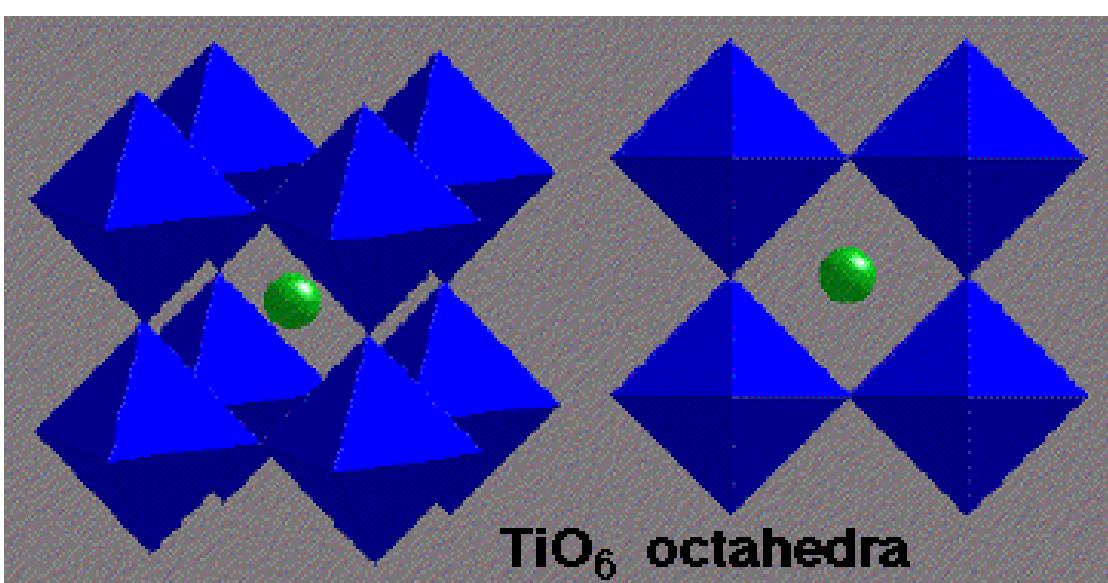


Mineral Perovskite: CaTiO_3

- Named after Russian mineralogist, Count Lev Aleksevich von Perovski
- Discovered by Gustav Rose in 1839 from samples found in Ural Mountains



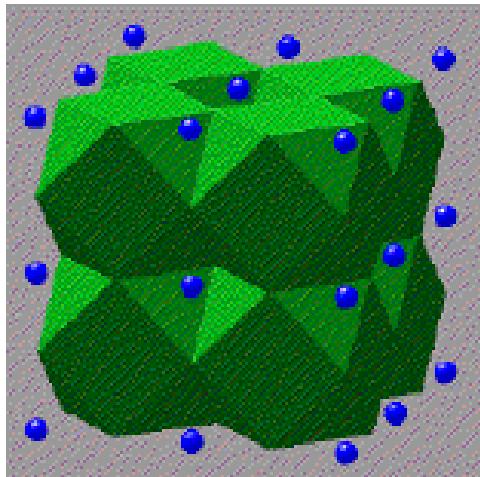
A-Cell



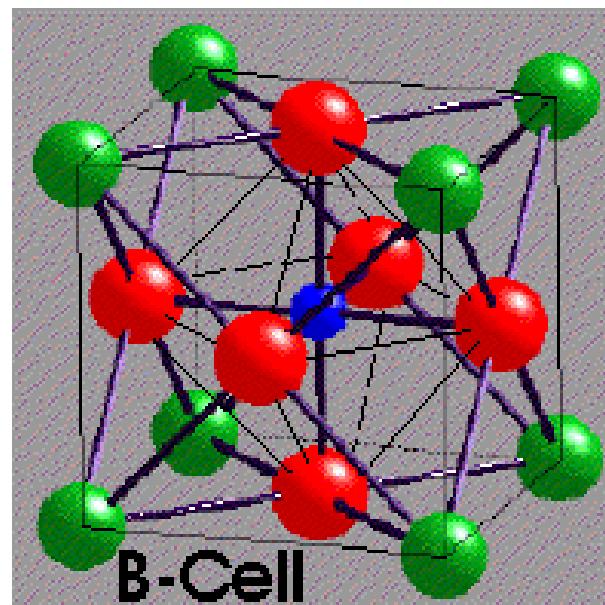
TiO₆ octahedra

Perovskite
 CaTiO_3

● Ca ● Ti ● O

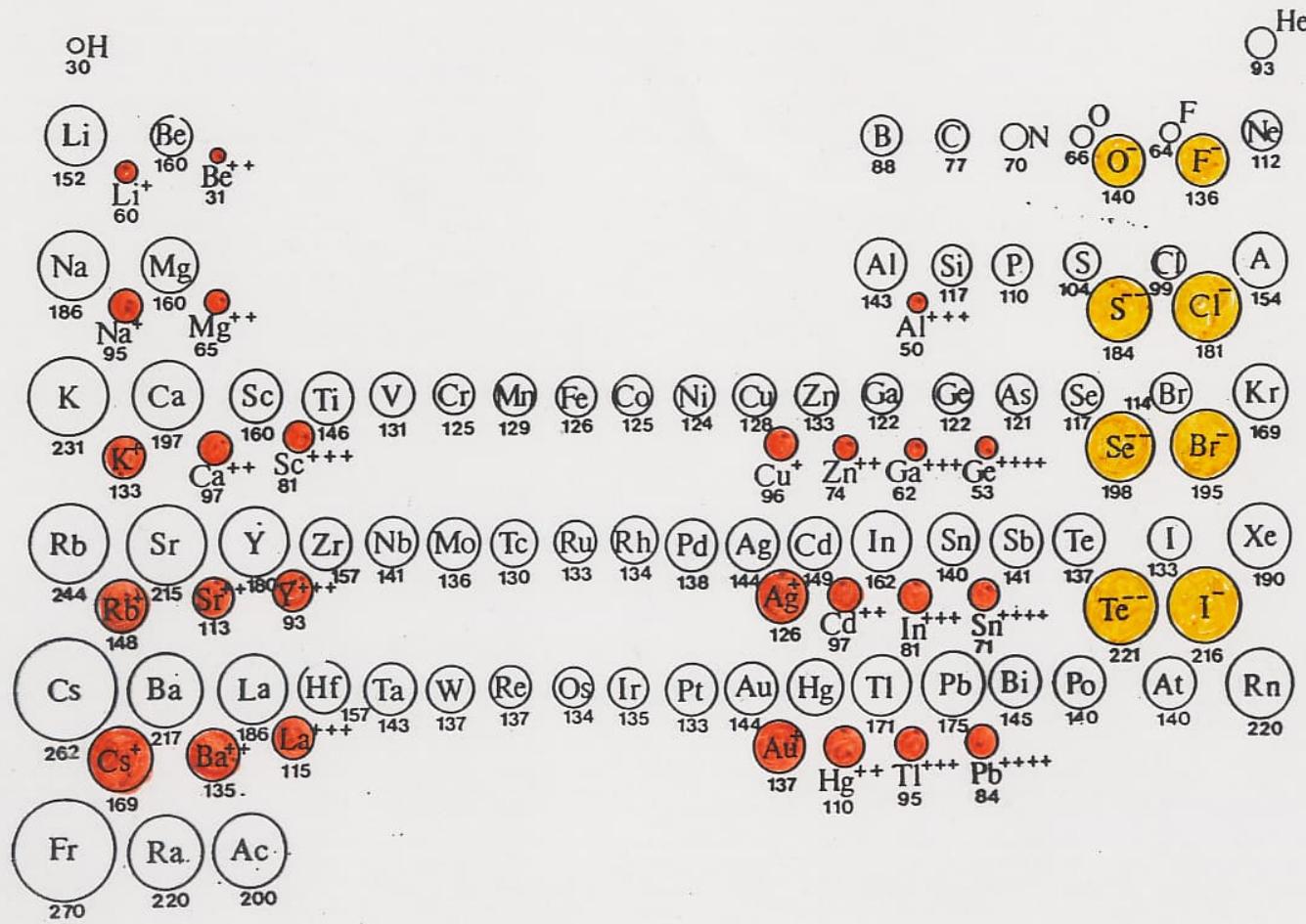


CaO₁₂ cuboctahedra



B-Cell

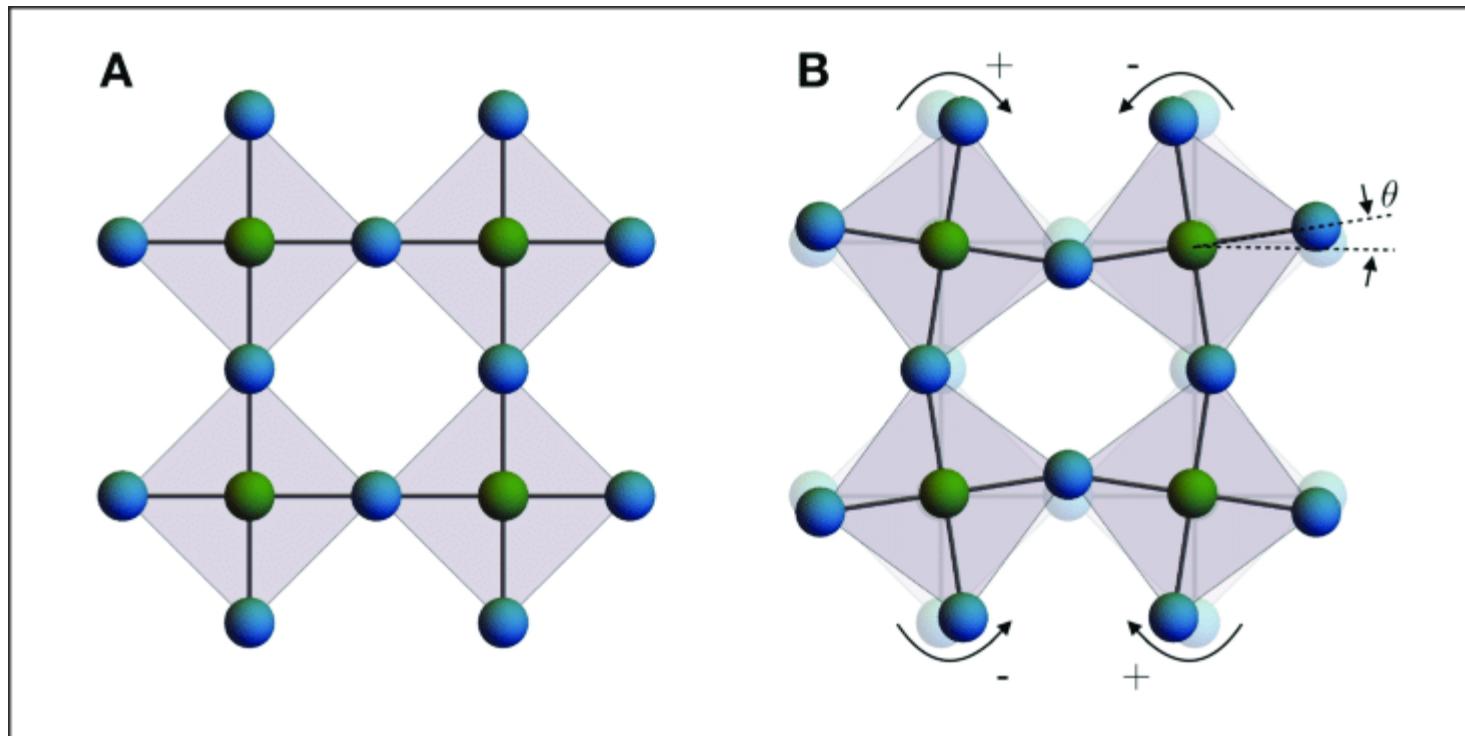
SIZES of ATOMS & IONS !!!



Ox. state	Ti	V	Cr	Mn	Fe	Co	Ni	Cu	Zn
+II	0.86	0.79	0.80	0.83	0.78	0.75	0.69	0.73	0.74
+III	0.67	0.64	0.62	0.65	0.65	0.61	0.60	0.54	-
+IV	0.61	0.58	0.55	0.53	0.59	0.53	0.48	-	-

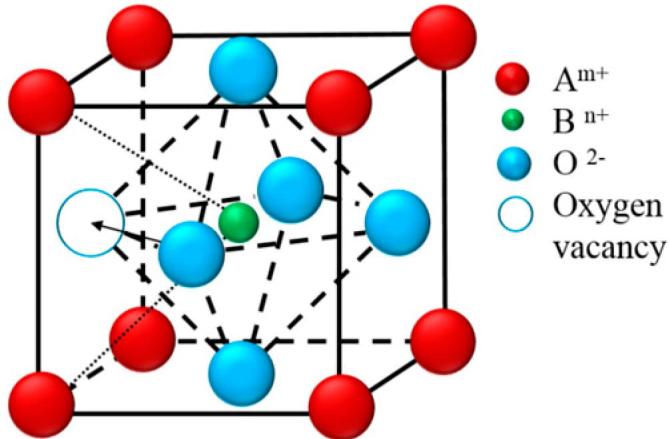
DISTORTIONS in ABO_3

- Atoms (typically oxygen atoms) are often slightly displaced from their ideal positions
- This ends up with tilting of the BO_6 octahedra
- These **distortions affect many properties** (magnetic, ferroelectric, etc.)

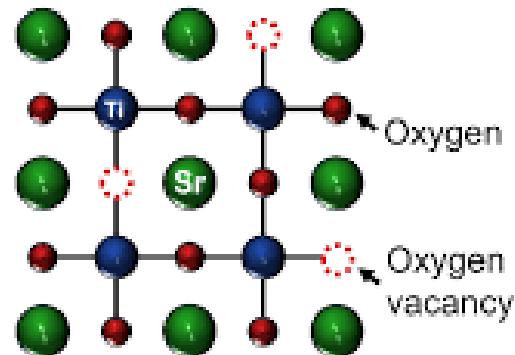


OXYGEN DEFICIENCY in $\text{ABO}_{3-\delta}$

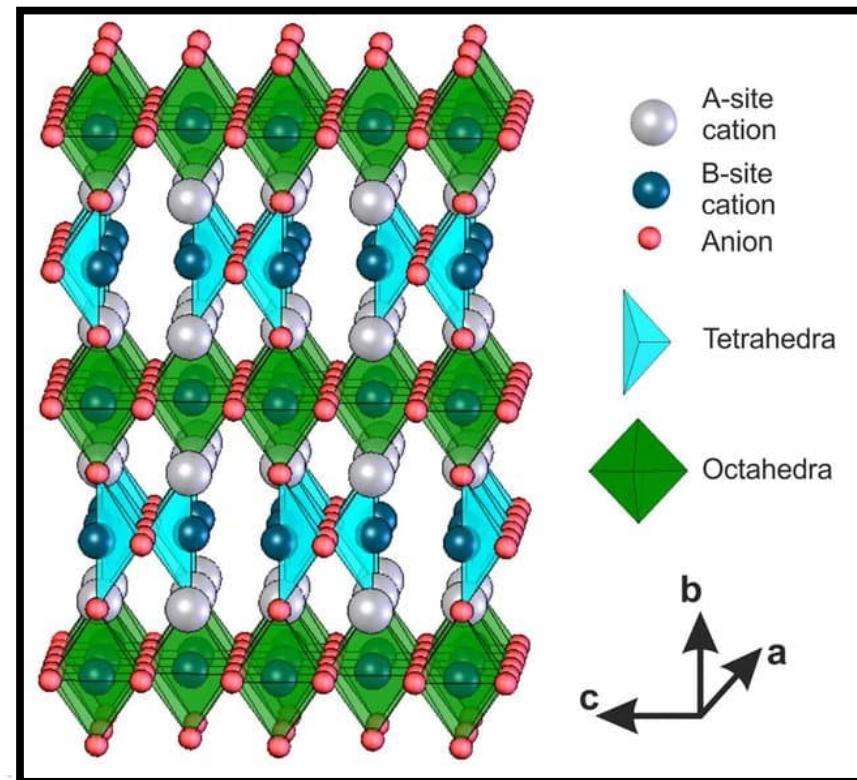
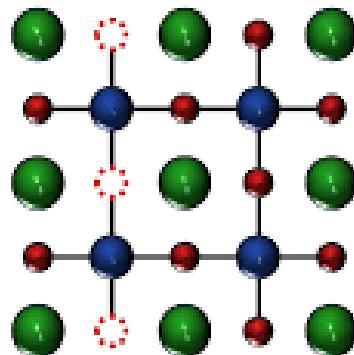
- Oxygen deficiency even up to $\delta = 0.5$ is common for perovskite compounds
- **Oxygen content controls metal valences → properties**
- Location of oxygen vacancies: random or ordered



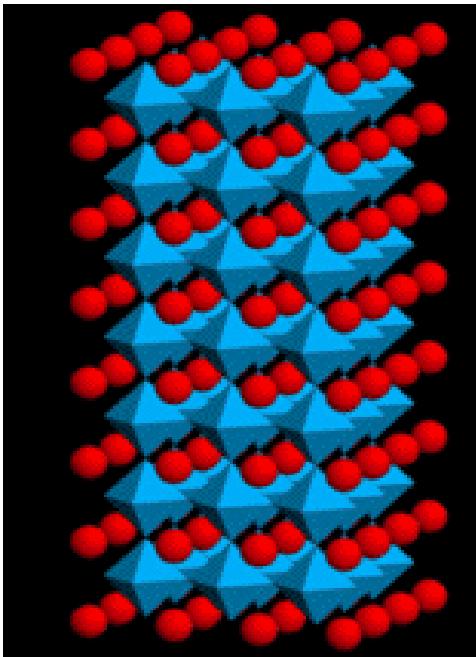
Random



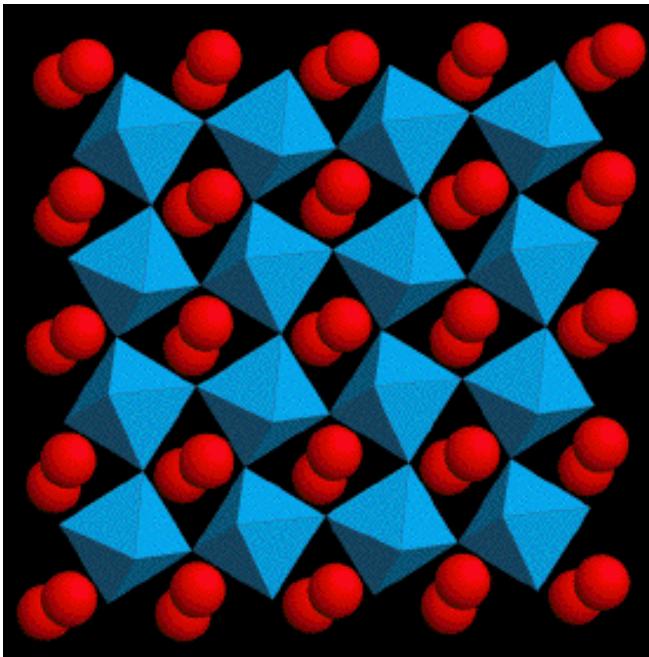
Ordered



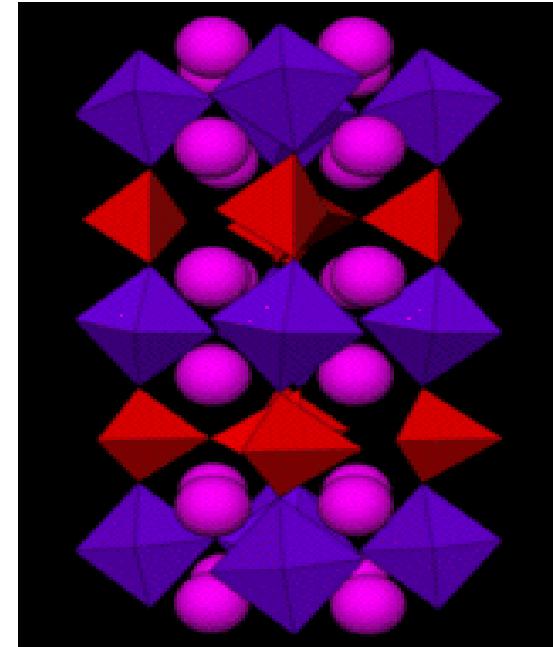
Distortions and deficiencies in Perovskite Structure: - often the source of the desired properties



IDEAL



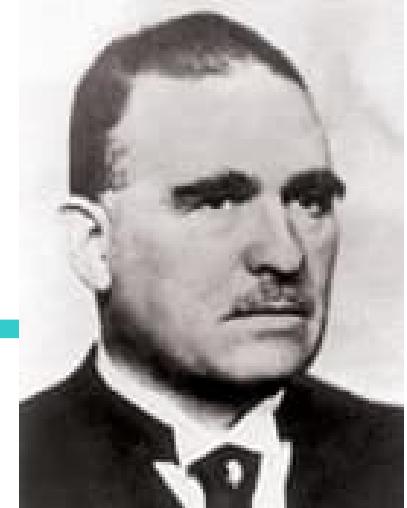
Changes in
atomic positions



Oxygen
deficiency

Let's talk more about these distortions/deficiencies

Victor Moritz Goldschmidt
(1888-1947)

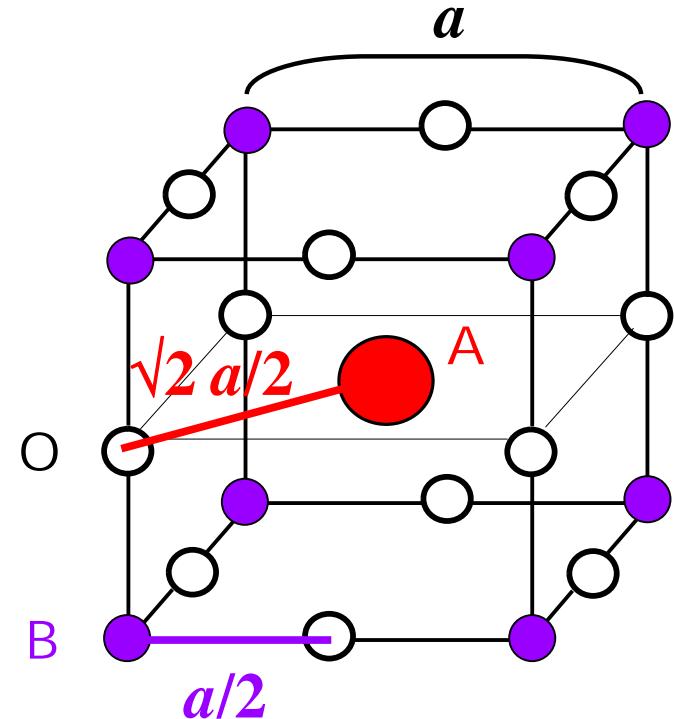


TOLERANCE FACTOR (t)

- 1926 Goldschmidt
**V.M. Goldschmidt , “Geochemische Verteilungsgesetze der Elemente”,
Skrifter Norske Videnskaps-Akad, Oslo, I. Mat-Naturr. K1 (1926)**
- t: measure for the degree of mismatch between two different atomic layers
- Calculated from **preferred bond lengths**
- Preferred bond lengths are estimated from **ionic radii**
R.D. Shannon, Acta Cryst. A 32, 751 (1976)

Tolerance factor for ABO_3 perovskite

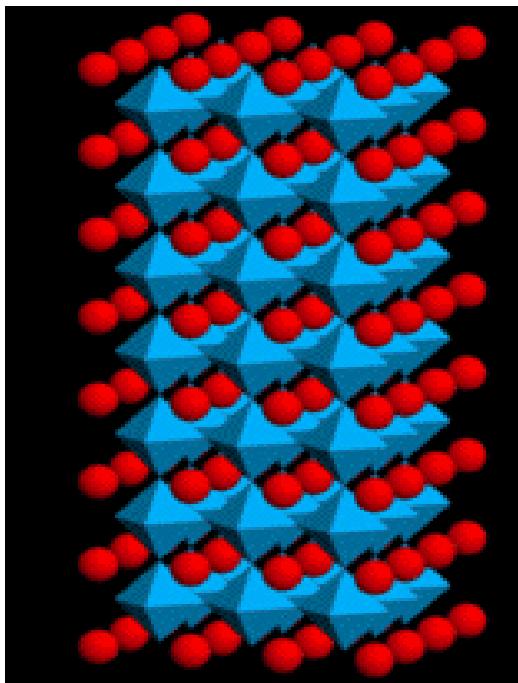
$$t = \frac{(r_A + r_O)}{\sqrt{2} (r_B + r_O)}$$



- $t = 1$: ideal matching ($0.80 < t < 1.05$ possible)
- $t < 1$: A is too small \rightarrow change in oxygen position
- $t > 1$: B is too small \rightarrow B reduced \rightarrow oxygen vacancies

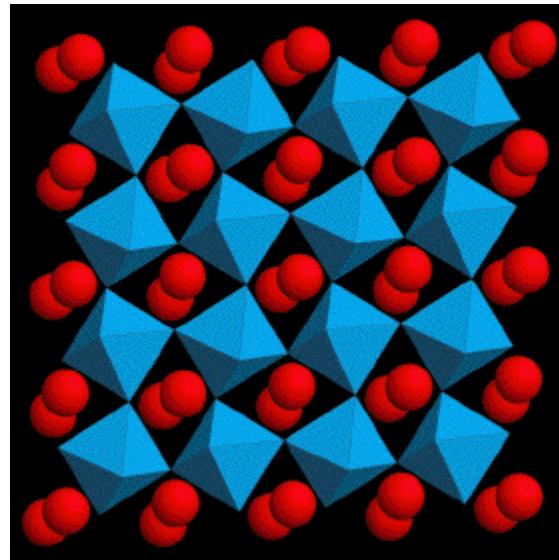
$$t = \frac{(r_A + r_O)}{\sqrt{2} (r_B + r_O)}$$

$t = 1$



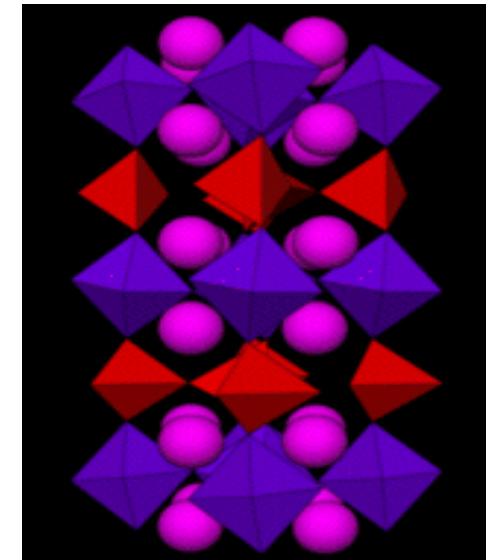
Ideal perovskite

$t < 1$



Changes in
atomic positions

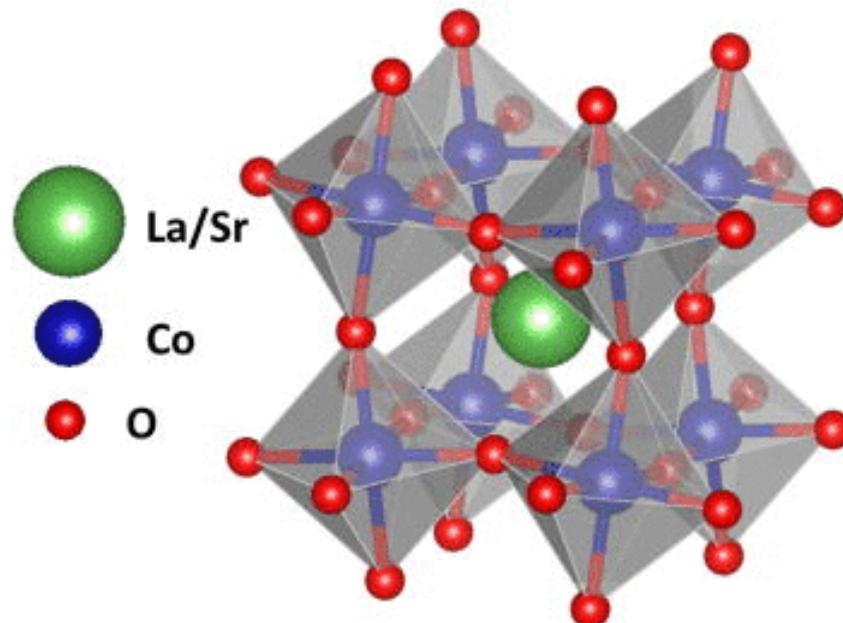
$t > 1$



Oxygen deficiency

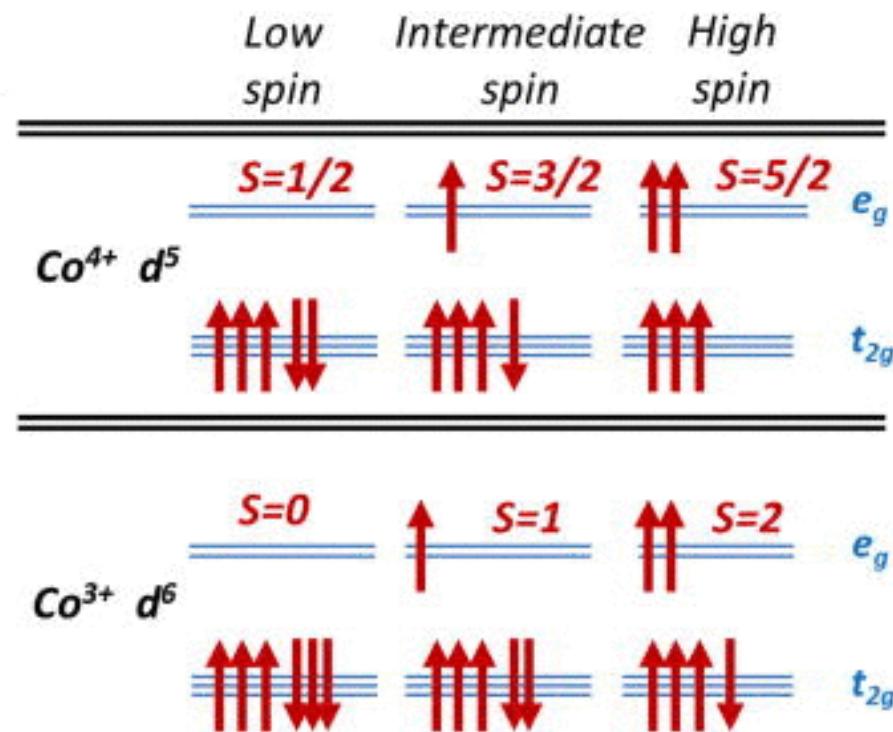
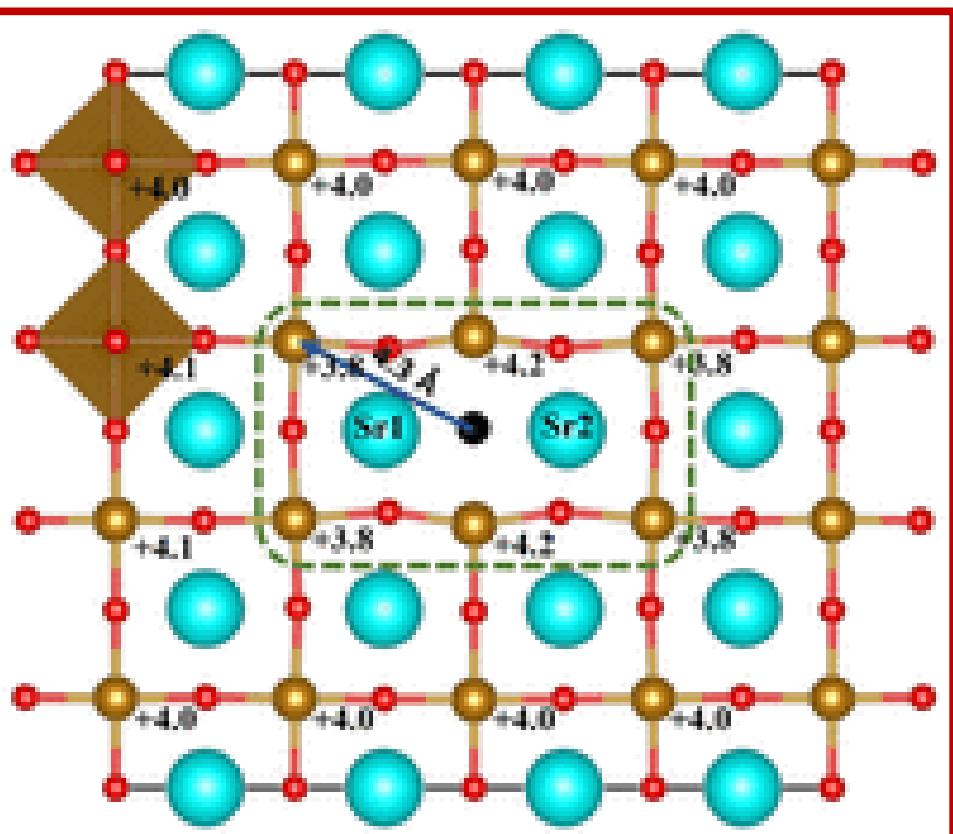
ALIOVALENT SUBSTITUTIONS in PEROVSKITES

- “Doping”: creates mixed valency
- For example: Sr^{2+} -for- La^{3+} substitution in $(\text{La}, \text{Sr})\text{CoO}_3$
- Type of doping ? Typical substitution level ?
- Effect on Co valence ?
- What else may happen ?



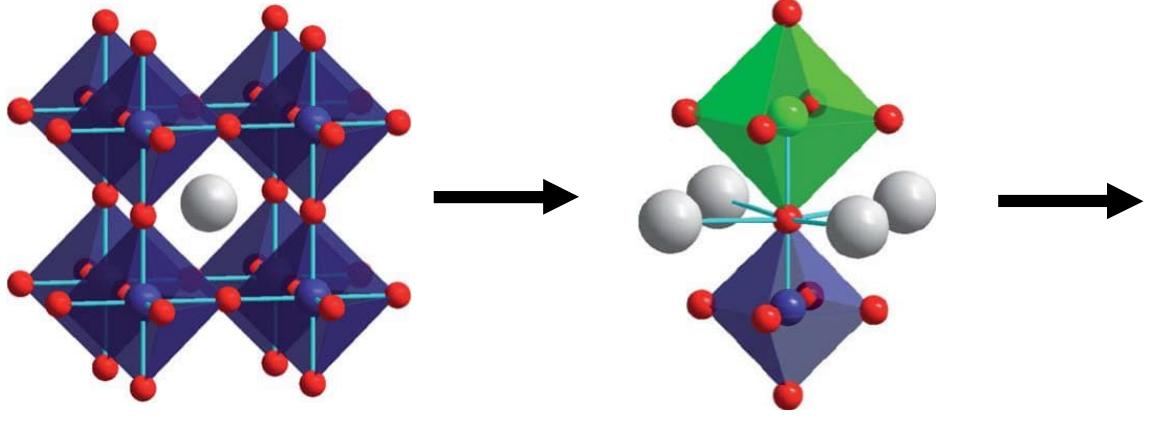
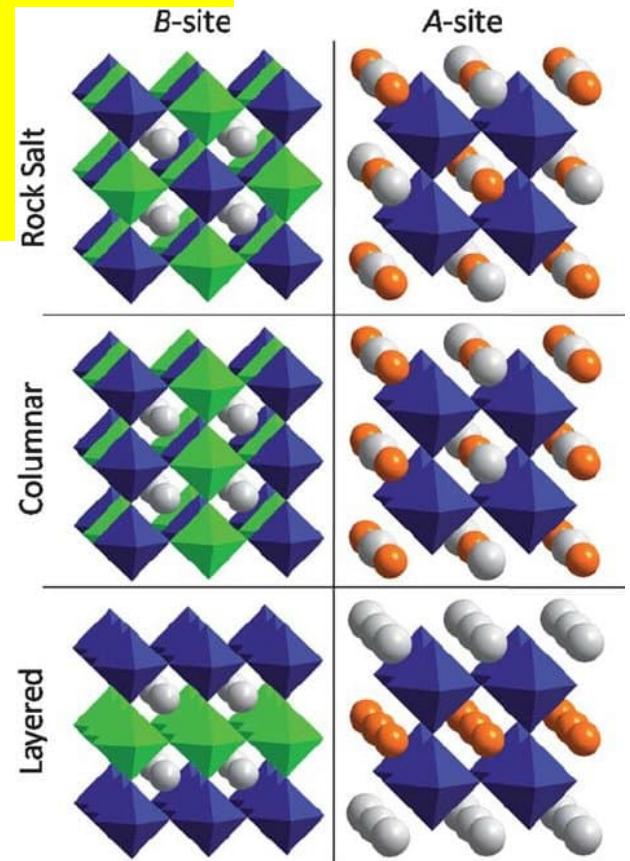
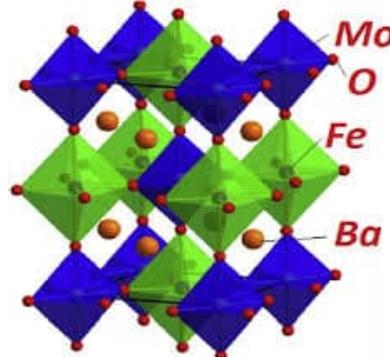
ALIOVALENT SUBSTITUTION in $(\text{La}^{3+}, \text{Sr}^{2+})\text{CoO}_{3-\delta}$

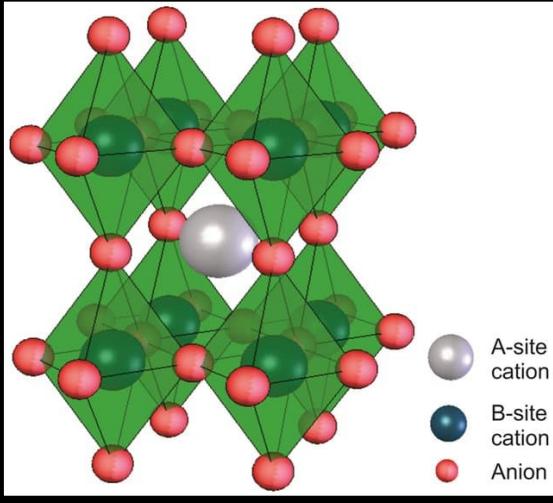
- Cobalt partly oxidized: $\text{Co}^{3+} \rightarrow \text{Co}^{4+}$
- Oxygen vacancies created
- Balance: metal redox versus oxygen vacancies
- Possible chemical pressure effects (c.f. isovalent substitution)
- Effects on electrical cond., ionic cond. & magnetic properties ?



DOUBLE & TRIPLE PEROVSKITES

- FOR EXAMPLE: Two different cations (**B'** and **B''**) occupy the B-site with 50%/50% ratio and in an ordered manner
→ B-site ordered double perovskite
- Example of B-site ordered double perovskites:
 $\text{Sr}_2\text{FeMoO}_6$ (ferrimagnetic halfmetal)
- Similarly, there are A-site ordered double perovskites
- There are also triple perovskites, e.g. $\text{A}'\text{A}''_2\text{B}_3\text{O}_9$
- Example of (oxygen-deficient) triple perovskites:
 $\text{YBa}_2\text{Cu}_3\text{O}_7$ (high- T_c superconductor)





Perovskite ABO_3

- No space for interstitial oxygen

Ruddlesden-Popper $\text{A}_{n+1}\text{B}_n\text{O}_{1+3n}$

- Enough space for interstitial oxygen

